Special Issue

Thermal Analysis and Multi-Scale Modeling for Chemical Processes

Message from the Guest Editors

The purpose of this Special Issue is to present a collection of papers that reflect recent developments in the field of multi-scale modeling of chemical processes and highlight the essential role of thermal analysis in understanding the behavior of various chemical processes.

- Differential scanning calorimetry (DSC)
- Thermogravimetric analysis (TGA)
- Process simulation
- Reaction kinetics
- Scaling

Guest Editors

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Deadline for manuscript submissions

closed (15 August 2023)



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You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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